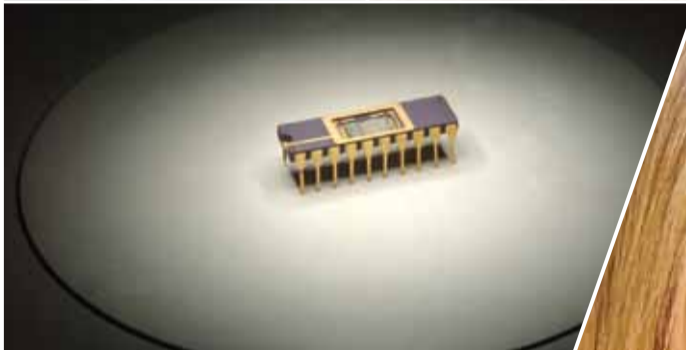




*fluorochemical excellence*

*shaping the future*



## ***Electronics***

Hydrofluoric acid and its derivatives such as fluorine gas, nitrogen trifluoride gas and tungsten hexafluoride gas are extensively used in the manufacture of silicon based semiconductor devices in etching and cleaning operations. Semiconductor devices include microprocessor chips and flash memory used in computers, automotive and aeronautical electronic systems, telephones, camcorders, ipods, memory sticks, televisions, LCD screens and domestic appliances.